Anal. Calcd for $C_{24}H_{20}SiCr: C, 74.23; H, 5.15$. Found: C, 73.03; H, 5.27.

Preparation of (1-6:1'-6'-\eta-Tetraphenylsilane)vanadium (7). The synthesis of 7 proceeded in analogy to that of 5. From 1.2 g (5.8 mmol) of bis(benzene)vanadium (12) 0.78 g (2.0 mmol, 35%) of 7 was obtained as glistening black stars. 7 decomposes at 225 °C before melting. MS (m/z (relative intensity)): 387 (M⁺, 100), all fragment ions I < 10%. Anal. Calcd for C₂₄H₂₀SiV: C, 74.73; H, 5.16. Found: C, 73.77; H, 5.48.

Preparation of Bis((triphenylsilyl)- η^{6} -benzene)chromium (6). A 1.3-g (6.3-mmol) amount of bis(benzene)chromium (9) was metalated as described above. A 4.45-g (15.1-mmol) portion of chlorotriphenylsilane, dissolved in 100 mL of petroleum ether, was then added to the cooled (0 °C) suspension with vigorous stirring. Filtration followed by partial extraction of the sparingly soluble solid residue with 250 mL of boiling toluene gave 100 mg (1.4 mmol, 2.4% yield) of 6 as a yellow-orange, amorphous powder. MS (m/z (relative intensity)): 724 (M⁺, 30), 388 (M⁺ - SiPh₄, 100), 336 (SiPh₄⁺, 25), 259 (SiPh₃⁺, 75), 182 (SiPh₂⁺, 40), 52 (⁵²Cr, 25). Anal. Calcd for C₄₈H₄₀Si₂Cr: C, 79.55; H, 5.52. Found: C, 79.65; H, 5.43.

Preparation of Bis((triphenylsilyl)- η^{6} -benzene)vanadium (8). The synthesis of 8 was performed as described for the chromium analogue 6. From 0.79 g (3.8 mmol) of bis(benzene)vanadium (12) 0.24 g (0.33 mmol, 8.7%) of 8 was obtained as maroon microcrystals. MS (m/z (relative intensity)): 723 (M⁺, 17), 387 (M⁺ - SiPh₄, 38), 336 (SiPh₄⁺, 49), 259 (SiPh₃⁺, 100), 182 (SiPh₂⁺, 62). Anal. Calcd for C₄₈H₄₀Si₂V: C, 79.64; H, 5.57. Found: C, 79.10; H, 5.88.

Cocondensation of Tetraphenylsilane with Chromium Atoms. A 1-g (3-mmol) amount of tetraphenylsilane (internal vaporization) and 0.52 g (10 mmol) of chromium were cocondensed at -196 °C (10⁻⁴ mbar) over 1 h. Extraction of the reaction mixture with toluene followed by removal of solvent under reduced pressure yielded an orange solid. According to ¹H NMR specProtodesilylation of (1-6:1'-6'- η -tetraphenylsilane)chromium (5). A 50-mg amount of 5 (0.13 mmol) was dissolved in 50 mL of warm THF, giving a clear red-orange solution. To this was added 2.5 mL of N₂-saturated water. Within minutes, the solution turned yellow. Filtration through activated alumina and removal of solvent under reduced pressure, followed by recrystallization from ligroin, yielded 20 mg of a light tan powder, which was subjected to ¹H and ¹³C NMR and mass spectral analysis. MS (m/z (relative intensity)): 794 (10⁺, 17). ¹H NMR (C₆D₆): δ 7.85 (doublet of doublets, relative intensity 1), 7.71 (doublet of doublets, 4.2), 7.20 (m, 12), 4.23 (s, 6.5). ¹³C NMR (C₆D₆): δ 136.9 (C_{meta}), 134.8 (C_{para}), 130.9 (C_{ipso}), 129.9 (C_{meta}), 74.8 (9). From this analysis, it is apparent that the product is a mixture of primarily bis(benzene)chromium (9), poly(diphenylsiloxane), and traces of 10.

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Supplementary Material Available: A table of anisotropic temperature factors and atomic coordinates of the H atoms and a complete list of bond lengths and angles (3 pages); a table of the structure factors (9 pages). Ordering information is given on any current masthead page.

Theoretical Study of $Cp_2Ti(H)(SiH_3)$ and Cp_2TiSiH_2 and Their Possible Role in the Polymerization of Primary Organosilanes

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The two reactions $Cp_2Ti(H)(SiH_3) \rightarrow Cp_2Ti=SiH_2 + H_2$ and $Cp_2Ti=SiH_2 + SiH_4 \rightarrow Cp_2Ti(H)SiH_2SiH_3$ have been modeled with use of density functional theory and the HFS-LCAO program system by Baerends et al. Both kinetic and thermodynamic features of these reactions were studied, and the results of the computations indicate that the first reaction can proceed with a moderate activation barrier of ca. 60 kJ mol⁻¹ and an enthalpy of ca. 40 kJ mol⁻¹. The second reaction is found to be exothermic (ca. -48 kJ mol⁻¹) with an activation barrier of ca. 12 kJ mol⁻¹. The previously proposed mechanism for the titanocene-catalyzed dehydrocoupling of organosilanes is evaluated in terms of these calculations, and it is concluded that the α -hydride elimination-silane addition route is viable. The structural and thermodynamic parameters for each of the important reaction intermediates are also calculated.

I. Introduction

It has recently been shown that the polymerization of primary organosilanes¹ can be catalyzed by dehydrocoupling under the influence of titanocene-based catalysts, according to eq 1.

 $n\text{RSiH}_3 \rightarrow \text{RH}_2\text{Si}[\text{SiRH}]_{n-2}\text{SiH}_2\text{R} + (n-1)\text{H}_2 \quad (1)$

This reaction is close to thermodynamically neutral. The enthalpy for the elementary dimerization reaction $RSiH_3 + R'SiH_3 \rightarrow RH_2SiSiH_2R'$ (2) can be estimated with use of literature bond energy values² as

$$\Delta H_2 = 2[D(\text{Si}-\text{H})] - D(\text{H}-\text{H}) - D(\text{Si}-\text{Si})$$

= (786 - 432 - 340) kJ mol⁻¹ = 14 kJ mol⁻¹

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This slight endothermicity is probably overcome by the easy loss of hydrogen from the system.

It was proposed^{1f} that the key intermediate in the chain-propagation step is $Cp_2Ti(H)(SiH_2R)$ and that this intermediate may undergo an α -hydride elimination to give a molecule of hydrogen and a silylene complex of titanocene:

$$Cp_2Ti(H)(SiH_2R) \rightarrow Cp_2Ti=SiHR + H_2$$
 (3)

Chain extension was the proposed to occur by addition of a molecule of RSiH₃ across the silylene-metal bond (eq 4).

$$Cp_2Ti = SiHR + RSiH_3 \rightarrow Cp_2Ti(H)(SiHRSiH_2R)$$
 (4)

Although silvlene complexes of other metals have been reported,^{3,4} such complexes of titanium are hitherto unknown.

The theoretical study reported in the present paper is based on density functional theory⁵ and the HFS-LCAO program system of Baerends⁶ et al. The study had two objectives, the first of which was to analyze the thermodynamics of the two postulated steps (3) and (4) by using the model reactions

$$Cp_2Ti(H)(SiH_3) \rightarrow Cp_2TiSiH_2 + H_2$$
 (5)

$$Cp_2TiSiH_2 + SiH_4 \rightarrow Cp_2Ti(H)(SiH_2SiH_3)$$
 (6)

The second objective was to study the molecular and electronic structures of the reactive silylene (Cp₂Ti=SiHR) and the hydridosilyltitanocene $(Cp_2Ti(H)(SiH_3))$ complexes, neither of which has been characterized experimentally.

We shall finally carry out exploratory calculations on the reaction profiles for the two model processes in order to get an estimate (upper bound⁷) of the activation barriers.

II. Computational Details

The calculations presented here were carried out with the LCAO-HFS program system developed by Baerends⁶ et al. and recently vectorized by Ravenek.^{6d} Extensive use has been made of the numerical integration scheme developed by Becke.⁸ Bond energies were evaluated by the generalized transition state method,⁹ and geometry optimizations were carried out according to the algorithm developed by Versluis¹⁰ and Ziegler. Total energies, E, were evaluated according to

$$E = E_{\rm HFS} + E_{\rm c} + E_{\rm X}^{\rm NL} \tag{7}$$

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Here $E_{\rm HFS}$ is the total statistical energy expression for the Hartree-Fock-Slater (HFS) or $X\alpha$ method¹¹ and E_c and E_X^{NL} are additional correction terms. The first correction term, E_c , has been proposed by Stoll¹² et al. It represents correlation between electrons of different spins, which is lacking in the original HFS method. The second correction term, E_X^{NL} , has been proposed by Becke¹³ and represents a nonlocal correction to the local HFS exchange energy. The correction term $E_{\rm c}$ was based on Vosko's parametrization¹⁴ from electron gas data. The molecular orbitals were expanded as a linear combination of Slater type orbitals (STO).⁶ An uncontracted triple-5 STO basis set¹⁵ was employed for the transition metals. The basis set on the ligands was of double-5 quality. For Si the basis was augmented by a single STO d orbital ($\zeta_{3d}^{Si} = 1.3$). For all H atoms not on the Cp rings a 2p polarization STO function of $\zeta_{2p}^{H} = 1.0$ was used. A set of auxiliary¹⁶ s, p, d, f, and g STO functions, centered on all nuclei, was used in order to fit the moleculr density and present Coulomb and exchange potentials accurately in each SCF cycle. The orbitals in the upper 3s, 3p, 3d, 4s, and 4p shells on Ti and the upper ns and np shells on the main-group atoms were considered as valence, whereas orbitals in shells of lower energies were considered as core and frozen according to the procedure by Baerends⁶ et al. Standard geometries were adopted for C_5H_5 (Cp). The exchange factor⁶ $\alpha_{\rm ex}$ in the expression for $E_{\rm HFS}$ was given a value of $^2/_3$ in accordance with Becke's theory.⁵ Calculations on metal carbonyls,¹⁷ binuclear metal complexes,¹⁸ and alkyl and hydride complexes,19 as well as complexes containing M-L bonds for a number of different ligands,²⁰ have shown that the calculations based on the energy expression given in eq 7 afford metal-ligand and metal-metal bond energies of nearly chemical accuracy (±5 kcal mol⁻¹). Approximate density function methods have also been tested in connection with vibrational frequencies,²¹ conformational energies,²² and triplet-singlet separations.²³ More than 50 molecular structures optimized by approximate density functional theory have been compared with experimental structures.¹⁰ The agreement between experimental and approximate density functional structures is in most cases excellent.

III. Electronic Structure of $(C_5H_5)_2$ Ti and $(C_5H_5)_2Ti(H)(SiH_3)$

The frontier orbitals of the $Cp_2Ti d^2$ system (1) has been studied by Lauher²⁴ and Hoffmann. The coordinatively unsaturated d² fragment of C_{2v} point-group symmetry has three nearly degenerate²⁵ d-based frontier orbitals, $1a_1$ (2a), $1b_1$ (2b), and $2a_1$ (2c).

We have found the Cp_2Ti has a 3B_1 ground state with the electronic configuration $(1a_1)^1(1b_1)^1$. The optimized

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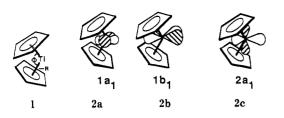
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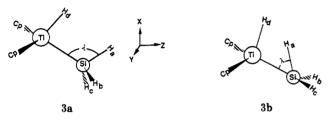
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 (23) Ziegler, T.; Rauk, A.; Baerends, E. J. Theor. Chim. Acta 1977, 43,
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- (24) Lauher, J. W.; Hoffmann, R. J. Am. Chem. Soc. 1976, 98, 1729. (25) The orbital energies for $1a_1$, $1b_1$, and $2a_1$ were calculated to be
- -2.29, -2.27, and -2.21 eV, respectively.

⁽¹¹⁾ Slater, J. C. Adv. Quantum Chem. 1972, 6, 1.

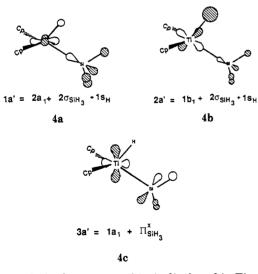


structure for the triplet ground state had a Φ value for 1 of 180° and an R value for 1 of 2.04 Å. The first excited state was calculated to be the ¹A₁ singlet with the (1a₁)² configuration. The optimized structure of ¹A₁ is very similar to that of the triplet ground state with $\Phi = 180^{\circ}$ and R = 2.05 Å. The ¹A₁ state is 70 kJ mol⁻¹ higher in energy than ³B₁.

The bonding in the d⁰ hydrido silyl complex CpTi-(H)(SiH₃) (**3a**), with C_s point-group symmetry, can be understood readily in terms of the Cp₂Ti fragment orbitals **2a-2c**, as well as the valence orbitals of H (1s_H) and SiH₃ $(2\sigma_{\text{SiH}_3}, \Pi_{\text{SiH}_3}^{x}, \text{ and } \Pi_{\text{SiH}_3}^{y})$. The orbitals of importance for



the bonding between Cp₂Ti and the two ligands H and SiH₃ are 4a-4c, where 4a and 4b account for the Ti-H and Ti-Si σ -bonds in 3a whereas 4c represents a stabilizing donation from the occupied $\Pi_{SiH_3}^{*}$ orbital to the Ti-based 1a₁ orbital (2a). The energies of 4a-4c are given on the left side of Figure 1.



The optimized structure of 3a is displayed in Figure 2A. The unique hydrogen on the SiH₃ group does not exhibit any agostic behavior, and the three Si-H bond distances are quite similar.

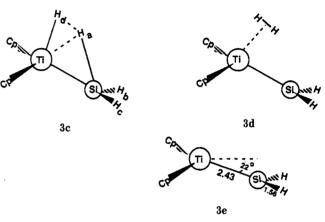
The total enthalpy for the reaction

$$TiCp_2 + H + SiH_3 \rightarrow Cp_2Ti(H)(SiH_3)$$
(8)

was calculated to be -370.5 kJ mol⁻¹. The individual Ti-H and Ti-SiH₃ bond energies were calculated to be $D_e(\text{Ti-H})$ = 245.6 kJ mol⁻¹ and $D_e(\text{Ti-SiH}_3) = 124.9$ kJ mol⁻¹ in the case where H is disrupted from Cp₂Ti(H)(SiH₃) before SiH₃. The reverse process, where SiH₃ is disrupted before H, gave $D_e(\text{Ti-H}) = 257.1$ kJ mol⁻¹ and $D_e(\text{Ti-SiH}_3) =$ 113.4 kJ mol⁻¹. The Ti-SiH₃ bond is in both cases seen to be considerably weaker than the Ti–H bond. We note finally that the addition of SiH_4 to $TiCp_2$ is calculated to be an exothermic process with a reaction enthalpy of -41.4 kJ mol⁻¹.

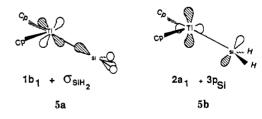
IV. Elimination of H₂ from Cp₂Ti(H)(SiH₃) and the Electronic and Molecular Structure of the Silylene Complex Cp₂Ti(SiH₂)

As already mentioned, it has been suggested¹ that the H_2 elimination from CpTi(H)(SiH₃) in eq 5 is a key step in the titanocene-catalyzed silane polymerization. The process in eq 5 can be viewed as a migration of the H_a atom in 3a toward the H_d ligand with the subsequent formation of the silylene dihydrogen adduct 3d, from which H_2 is eliminated with the formation of the reactive silylene species 3a.



To test the viability of this hypothesis, we have carried out calculations on the molecular and electronic structure of the silylene complex 3e as well as the reaction enthalpy for the process in eq 5. We have further attempted to trace the reaction profile for the key step in eq 5. It is not computationally feasible at the present time to explore the entire reaction surface for the process in eq 5. Our suggested reaction profile is, as a consequence, approximate, and the calculated activation barriers will constitute upper bounds to the actual barriers.

Calculation on Cp₂TiSiH₂ revealed (3e) a relatively short Ti-SiH₂ bond with $R(Ti-SiH_2) = 2.43$ Å, compared to $R(Ti-SiH_3) = 2.68$ Å in 3a. The short Ti-Si distance is indicative of a double bond established by the two interactions 5a and 5b, where 5a represents the σ -bonding Ti-SiH₂ interaction between 1b₁ (2b) of Cp₂Ti and σ_{SiH_2} , whereas 5b accounts for the Ti-silylene π -interaction between 1a₁ (2a) and the nonbonding 3p orbital on Si.



The structure **3a** represents an energy minimum on the energy potential with a positive Hessian matrix. The normal mode of lowest frequency, which could possibly lead toward the product **3d**, is represented by the rocking mode of the SiH₃ group in which the angle λ of **3a** is changed. Thus, this mode was chosen as the reaction coordinate for the initial stages of the process in eq 5. We have as a consequence carried out a rotation of the SiH₃ ligand in which the angle λ of **3a** is changed from $\lambda = 113^{\circ}$ to $\lambda = 50^{\circ}$ while the H_a atom remains in the symmetry

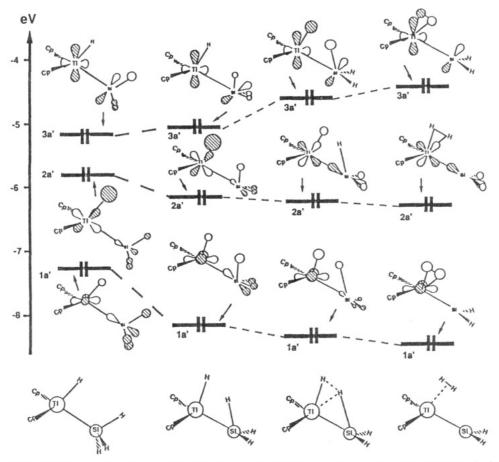
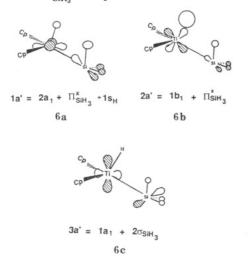


Figure 1. Correlation diagram for the occupied 1a', 2a', and 3a' orbitals in the process $3a \rightarrow 3d$. Orbitals of the hydrido silyl complex 3a are shown to the left and the orbitals of the silylene dihydrogen adduct 3d to the right.

plane of the Cp₂Ti(H)(SiH₃) species. This rotation leads to the new intermediate **3b**, for which we give the optimized structure in Figure 2B. During the rotation the remaining degrees of freedom were optimized. The structure **3b** represents an energy minimum with a positive Hessian matrix. In the rotation the role of the $\Pi_{\text{SiH}_3}^x$ and $2\sigma_{\text{SiH}_3}$ orbitals are interchanged. That is, the $\Pi_{\text{SiH}_3}^x$ orbital is now responsible for the Ti–Si σ -interactions in 1a' (**6a**) and 2a' (**6b**), whereas $2\sigma_{\text{SiH}_3}$ is responsible for the back-donation



to the metal center in 3a' (6c). However, bonding in the two conformers 3a and 3b is quite similar except for this interchange. The 1a', 2a', and 3a' orbitals of 3a and 3b, respectively, are correlated in Figure 1.

It follows from Figure 3A, where we display the reaction profile for the process in eq 5, that the rotation $3a \rightarrow 3b$

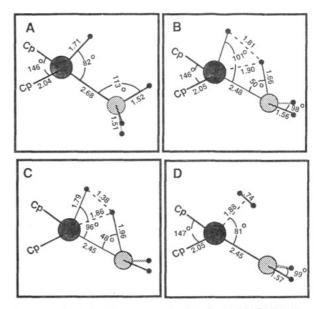


Figure 2. Optimized structures for (A) $Cp_2Ti(H)(SiH_3)$ of conformation 3a, (B) $Cp_2Ti(H)(SiH_3)$ of conformation 3b, (C) the approximate transition state for the migration process $3b \rightarrow 3d$, and (D) the optimized silylene dihydrogen adduct 3d.

has an enthalpy of 32 kJ mol⁻¹ and an activation barrier of 53 kJ mol⁻¹. The profile for the step $3a \rightarrow 3b$ was, as already specified, obtained by a linear transit procedure, and the calculated value for the barrier represents, as a consequence, an upper bound for the actual barrier. It follows from the optimized structure of **3b** given in Figure 2B that the H_a atom now is close enough ($R(Ti-H_a) = 1.90$ Å) to the Ti center for an agostic interaction. The agostic

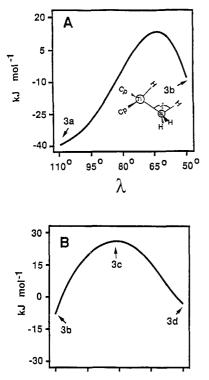
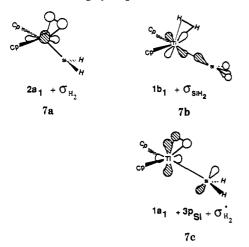


Figure 3. Reaction profile for (A) the rotation step $3a \rightarrow 3b$ and (B) the migration step step $3b \rightarrow 3d$.

interaction is particularly pronounced in **6a**. Note further that the Si–H_a bond distance has been elongated to 1.66 Å.

The remaining part of the process in eq 5 was modeled by a migration, $3b \rightarrow 3c \rightarrow 3d$, of the H_a atom toward the H_d ligand with the formation of silylene dihydrogen adduct, 3d. During the migration all remaining degrees of freedom were optimized. The correlation of the 1a', 2a', and 3a' orbitals during the migration process, $3b \rightarrow 3c \rightarrow$ 3d, is given in Figure 1. It follows that the 1a' orbital correlates with the (largely) H₂ σ -orbital (7a) of the silylene



dihydrogen intermediate 3d, whereas 2a'(7b) becomes the Ti-silylene σ -bonding orbital (5a) and 3a'(7c) the Ti-silylene π -bonding orbital (5b). The 3a'(7c) orbital is further stabilized in 3d by the interaction with the σ^* orbital of H₂. The profile for the migration, obtained by a linear transit as specified above, is given in Figure 3B, and the structures of the approximate transition state 3c as well as the silylene dihydrogen adduct 3d are given in Figure 2. It should be pointed out that the transition-state structure 3c is approximate since it is found from a linear transit rather than from a search for an energy extremum

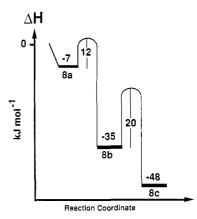


Figure 4. Schematic reaction profile for the reaction $8a \rightarrow 8c$.

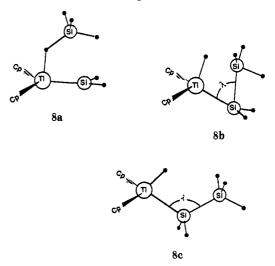
with one negative force constant. The migration step is seen to have a modest reaction enthalpy of 8 kJ mol⁻¹ with an activation barrier of only 33 kJ mol⁻¹. Part of the reason for the low activation barrier is the fact that the 1s orbital on the migrating H_a atom can have a stabilizing interaction with the empty $1a_1$ (2a) and $2a_1$ (2c) orbitals of Cp₂Ti in the transition state 3c, where $R(Ti-H_a) = 1.86$ Å (see Figure 1).

The adduct 3d between H_2 and $Cp_2Ti(SiH_2)$ represents the last stage in the reaction of eq 5 before H_2 is eliminated. The adduct 3d, in which the H-H distance has reached the value of free H_2 , is only held together by 3 kJ mol⁻¹. We note further that the $Cp_2Ti(SiH_2)$ framework in 3d (see Figure 2D) largely has reached the geometry of the free silylene complex $Cp_2Ti(SiH_2)$ (3e).

V. Addition of SiH₄ to Cp₂TiSiH₂

The addition process in eq 6 represents the reverse of eq 5 in that a σ -bond now is added rather than eliminated. The process in eq 6 has been modeled in a way similar to that for eq 5.

We allow first for the formation of the σ -adduct 8a between SiH₄ and the silylene complex 3e. The adduct 8a has a modest calculated formation energy of only 7 kJ mol⁻¹ as is indicated in Figure 4, where we give the energy profile for the reaction in eq 6.



We allow in the next stage of the process the silyl group to slide toward the silylene with the formation of the intermediate 8b. The optimized structure for 8b, which represents an energy minimum with a positive Hessian matrix, is given in Figure 5A. The silyl group in 8b is seen to have close bonding distances to the central metal, R-(Ti-Si) = 2.63 Å, and the hydride, R(Si-H) = 1.78 Å, as

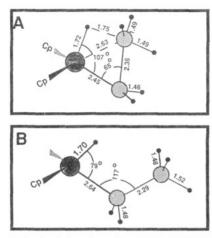
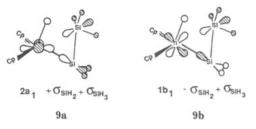
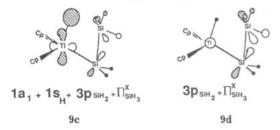


Figure 5. Optimized structures for (A) $Cp_2Ti(H)(SiH_2SiH_3)$ of conformation 8b and (B) $Cp_2Ti(H)(SiH_2SiH_3)$ of conformation 8b.

well as to the silylene, R(Si-Si) = 2.35 Å. The two Ti-Si σ -bonds are established in the orbitals **9a** and **9b** from



bonding interactions between $2\sigma_{SiH_3}$ and σ_{SiH_2} and respectively $2a_1$ and $1b_1$ of the Cp_2Ti fragment. Note that the SiH₃ group is rotated in such a way as to allow for the two σ -interactions in 8a and 8b. The Si–Si σ -bond is established between $3p_{Si}$ of the SiH₂ group and $\Pi_{SiH_3}^{*}$ of SiH₃ in 9d, whereas the Ti–H bond stems from the interaction in 9c between $1s_H$ and $1a_1$.



We calculate the passage $8a \rightarrow 8b$ to be exothermic with $\Delta H = -28 \text{ kJ mol}^{-1}$. The corresponding barrier was determined, from a linear transit, to be 12 kJ mol⁻¹ (see Figure 4).

The last step, $8\mathbf{b} \rightarrow 8\mathbf{c}$, in the process of eq 6 represents an opening of the λ angle from $\lambda = 65^{\circ}$ in $8\mathbf{b}$ to $\lambda = 117^{\circ}$ in $8\mathbf{c}$, with the formation of the hydrido silyl complex $8\mathbf{c}$. The optimized structure for $8\mathbf{c}$ is given in Figure 5B. The passage $8\mathbf{b} \rightarrow 8\mathbf{c}$ was calculated to be exothermic by 13 kJ mol⁻¹ with a barrier of 20 kJ mol⁻¹ (see Figure 4).

VI. Concluding Remarks

We have here evaluated one of the possible mechanisms for the polymerization of primary organosilanes by a titanocene-based catalyst. The polymerization process is, as already mentioned, nearly thermoneutral with the enthalpy in eq 2 given by $\Delta H_2 = 14$ kJ mol⁻¹. It is thus reasonable to assume that the reaction is driven by the removal of H₂. The key step in the mechanism proposed by Harrod for the polymerization of primary organosilanes by a titanocene-based catalyst is the chain propagating process in eq 9. The estimated enthalpy for the reaction in eq 9 is

$$Cp_{2}Ti(H)(SiH_{2}R) + SiH_{3}R \rightarrow Cp_{2}Ti(H)(SiHRSiH_{2}R) + H_{2}$$
(9)

identical with that of the polymerization process in eq 2 with $\Delta H_{2a} = 2[D(\text{Si}-\text{H})] - D(\text{H}-\text{H}) - D(\text{S}-\text{Si}) = 14 \text{ kJ} \text{mol}^{-1}$. Our calculated enthalpy for the model reaction

$$Cp_2Ti(H)(SiH_3) + SiH_4 \rightarrow Cp_2Ti(H)(SiH_2SiH_3) + H_2$$
(10)

was -8 kJ mol⁻¹.

We have visualized the chain propagating reaction in eq 9, modeled here by the process in eq 10, as taking place in two steps. The first step (eq 5) is an α -hydride elimination from the SiH₃ group with subsequent loss of H₂ to give the Cp₂Ti=SiH₂ silylene. This step was calculated to have a reaction enthalpy of 40 kJ mol⁻¹. The second step is an addition (eq 6) of SiH₄ to Cp₂TiSiH₂, for which we calculate an enthalpy of -48 kJ mol⁻¹.

It is clear from our findings that the feasability of the proposed mechanism (eqs 5 and 6) depends on whether or not one can expect the endothermic step in eq 5, with a calculated enthalpy of 40 kJ mol⁻¹, to take place at ambient temperatures. We feel that this might very well be the case for two reasons. In the first place, the step in eq 5 can be driven by the removal of H₂, just as in the overall polymerization process of eq 2, which also is endothermic. In the second place, the step in eq 5 is dissociative. This could well lead to a $T\Delta S$ contribution to ΔG_{3a} of -40 kJ mol⁻¹ with the result that $\Delta G_{3a} \approx 0$.

A number of other possible mechanisms for the polymerization reaction exist. It should, however, be noted that all such mechanisms would have endothermic steps since the overall polymerization process is endothermic. Among the more likely alternative mechanisms for the formation of the Si–Si bonds in this type of reaction are σ -bond metathesis (eq 11)²⁶ and the insertion of a disilene, formed by β -hydride elimination from a metal silyl complex (eq 12).^{27,28}

$$Cp_{2}TiH_{2} + RH_{2}SiSiH_{2}R$$
(11)
H SiH_{2}R

$$C_{P_2}TISIRHSIH_2R \longrightarrow C_{P_2}TI \xrightarrow{H}_{H} H$$

$$H \xrightarrow{H}_{R} H$$

Acknowledgment. This investigation was supported by the Natural Sciences and Engineering Research Council of Canada. We thank the University of Calgary for access to their Cyber-205 computer installations.

⁽²⁶⁾ σ -bond metathesis has been suggested as a possible mechanism: Tilley, T. D. Personal communication. The endothermicity in such a mechanism would, at least in part, come from the endothermic hydrogen loss from the metallocene dihydride.

⁽²⁷⁾ Although mononuclear disilene complexes are thus far unknown, a dimeric platinum complex with a bridging group that appears to be a disilene species was recently reported.²⁶

⁽²⁸⁾ Zarate, E. A.; Tessier-Youngs, C.; Youngs, W. J. Am. Chem. Soc. 1988, 110, 4068.